

ALD 2023 - AVS 23rd International Conference on Atomic Layer Deposition

Veranstaltung - ALD 2023 - AVS 23rd International Conference on Atomic Layer Deposition

Titel	ALD 2023 - AVS 23rd International Conference on Atomic Layer Deposition
Wann	So, 23. Juli 2023 - Mi, 26. Juli 2023

Beschreibung

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The AVS 23rd International Conference on Atomic Layer Deposition (ALD 2023) featuring the 10th International Atomic Layer Etching Workshop (ALE 2023) will be a three-day meeting dedicated to the science and technology of atomic layer controlled deposition of thin films and now topics related to atomic layer etching.

Since 2001, the ALD conference has been held alternately in the United States, Europe and Asia, allowing fruitful exchange of ideas, know-how and practices between scientists. This year, the ALD conference will again incorporate the Atomic Layer Etching 2023 Workshop (ALE 2023), so that attendees can interact freely.

The conference will take place July 23 - July 26, 2023, at the Hyatt Regency Bellevue in Bellevue, Washington (East Seattle).

As in past conferences, the meeting will be preceded (Sunday, July 23) by one day of tutorials and a welcome reception. Sessions will take place (Monday-Wednesday, July 24-26) along with an industry tradeshow. All presentations will be audio-recorded and provided to attendees following the conference (posters will be included as PDFs). Anticipated attendance is 800+.

Learn more about this event by following Link:

<https://ald2023.avs.org/>

Lokalität - Bellevue, Washington

Standort	Bellevue, Washington
Ortsname	Bellevue
Bundesland	Washington
Land	US